

# Certificate of Analysis **IARM 328B**

Nickel Alloy 945X / UNS N09945 Certified Reference Material

#### Certified Values listed in wt.% with associated uncertainties

Al	$0.116 \pm 0.007$	В	$0.0010 \pm 0.0006$	C	$0.010 \pm 0.001$	Co	$0.063 \pm 0.008$
Cr	$20.5 \pm 0.2$	Cu	$2.0 \pm 0.1$	Fe	$15.0 \pm 0.2$	Mn	$0.077 \pm 0.007$
Мо	$3.12 \pm 0.05$	N	$0.006 \pm 0.001$	Nb	$3.99 \pm 0.05$	Ni	$53.7 \pm 0.5$
Р	$0.005 \pm 0.004$	S	$0.0006 \pm 0.0004$	Si	$0.05 \pm 0.02$	Ti	$1.53 \pm 0.03$
V	<b>0.014</b> ± 0.007	W	$0.04 \pm 0.01$				

## **Indicative Values listed in ppm**

Ag	(<1)	As (<10)	Bi (<10)	Ca (10)	Cd (<10)	Hf (<600)	Mg (13)
0	(20)	Pb (<100)	Re (<40)	Sb (<1)	Se (<20)	Sn (10)	Ta (100)
Υ	(<100)	Zn (<10)	Zr (20)				

#### **Description and Intended Use**

This CRM may come in the form of a solid disc or chips. The intended use of this CRM may include, but is not limited to, the calibration of instruments and the validation of analytical methods.

## **Interpretation of Data**

- 1. Certified values listed reflect analysis results submitted by qualified analytical laboratories using a combination of methods and instrumentation that emulate actual methods and instrumental techniques currently utilized in the analytical community, and are reported as wt% unless otherwise noted.
- 2. This material was tested using both the solid disks and chips prepared from individual sections of bar. The certified values are considered representative of the overall average composition of the material.
- 3. Any data reported and enclosed by a parentheses ( ) is a "best estimate" and is not certified. This data could not be quantified sufficiently for certification. It was, however, reported by enough laboratories to be considered as potentially present in the matrix of the material being examined.
- 4. "Provisional Certificate of Analysis" reports values that support a fully certified reference material; it also indicates that values may be in a continued process of statistical evaluation and are subject to change.
- 5. Chips are not certified for Oxygen analysis.



The following data and accompanying statements represent all pertinent information reported in the ILAP as it applies to the chemical characterization of this material.

	Ag	Al	As	В	Bi	С	Са	Cd	Со	Cr	Cu	Fe	Hf	Mg	Mn	Мо
1	0.00002	0.10	0.00003	0.000206	0.000005	0.008	0.0007	<0.0010	0.042	20.07	1.864	14.50	0.0565	0.0002	0.062	3.0165
2 3		0.1013 0.106	0.00042 <0.0010	0.0004 0.0004	<0.0010	0.0085 0.0091	0.0007 0.001		0.0539 0.056	20.26 20.2737	1.8923 1.93	14.681 14.72		0.001 0.0015	0.0684 0.07	3.019 3.0455
4		0.108	<0.0010	0.0004		0.0091	0.001		0.0566	20.2737	1.93 1.94	14.72		0.0015	0.07	3.0455
5		0.115		0.0015		0.0094	<0.001		0.0579	20.4267	1.98	14.838		0.002	0.071	3.093
6		0.1161		0.00155		0.00958			0.061	20.4457	2.0267	14.99		<0.0001	0.071	3.132
7 8		0.122 0.122		0.002		0.0104 0.011			0.0645 0.065	20.48 20.54	2.03 2.036	15.012 15.14		<0.001	0.0716 0.078	3.1332 3.14
9		0.122				0.0114			0.063	20.54	2.0535	15.14			0.078	3.14
10		0.1224							0.069	20.704	2.0539	15.2346			0.0902	3.20
11		0.1245							0.07	20.95	2.123	15.24			0.0932	3.202
12 13		0.1372							0.0973	21.03	2.581	15.2995			0.098	3.21
14																
15		0.440	0.0000	0.004		0.040	0.0040		0.000	00.5		4.5		0.0040	0.077	0.40
Mean STDV.		0.116 0.01	0.0002 0.0003	0.001 0.0007		0.010 0.002	0.0010 0.0008		0.063 0.01	20.5 0.3	2 0.2	15 0.3		0.0013 0.0007	0.077 0.01	3.12 0.07
	(<0.0001)	0.116	(<0.001)	0.0010	(<0.001)	0.010	(0.001)	(<0.001)	0.063	20.5	2.0	15.0	(<0.06)	(0.0013)	0.077	3.12
95% C.I.		0.007	ĺ	0.0006	` <u></u> .	0.001	,		0.008	0.2	0.1	0.2		,	0.007	0.05
Methods	IM	X,O,I,G	IM,I	O,I	IM,I	С	A,I	l	X,O,I,G	X,W,O,I,G	X,O,I,G	X,O,I,G	0	O,I,G,A	X,O,I,G	X,O,I,G
	N	Nb	Ni	0	Р	Pb	Re	S	Sb	Se	Si	Sn	Та	Ti	V	W
1	0.005	3.8497	53.0556	0.0004	0.0007	0.001	0.00333	0.0002	0.00009	<0.001	0.0193	0.0003	0.0002	1.384	0.00667	0.0219
2 3	0.00527 0.0055	3.90 3.921	53.12 53.3925	0.002 0.00243	0.0012 0.0013	0.0084 <0.0010		0.0002 0.0002	0.00009 <0.0010	<0.0020	0.02 0.0284	0.000338	0.004734 0.009	1.496 1.50	0.0073 0.009534	0.024559 0.026
4	0.005513	3.935	53.50	0.00243	0.0013	<b>\0.0010</b>		0.0002	<b>40.0010</b>		0.0204	0.002	0.003	1.518	0.009334	0.028
5	0.0061	3.9872	53.50	0.003	0.0028			0.001			0.033	<0.001	0.023	1.539	0.011	0.041
6	0.00673	3.99	53.613	<0.0005	0.0046			0.001			0.036	<0.0010	0.02667	1.542	0.011	0.042 0.06
8	0.0095	4.005 4.03	53.692 54.26		0.005 0.005			<0.0005 <0.001			0.037 0.039		<0.001	1.55 1.55	0.012 0.015	0.0601
9		4.04	55.05		0.005			<0.001			0.051			1.5527	0.0384	0.068
10		4.046			0.018						0.0547			1.562		
11 12		4.10 4.102									0.1209 0.1238			1.57 1.5827		
13		4.102									0.1230			1.3021		
14																
15 Mean	0.006	3.99	53.7	0.002	0.005	0.0047		0.0006			0.05	0.001	0.01	1.53	0.014	0.04
STDV.	0.000	0.08	0.6	0.002	0.005	0.0047		0.0004			0.03	0.001	0.01	0.05	0.014	0.04
Certified	0.006	3.99	53.7	(0.002)	0.005	(<0.01)	(<0.004)	0.0006	(<0.0001)	(<0.002)	0.05	(0.001)	(0.01)	1.53	0.014	0.04
95% C.I.	0.001 F	0.05 V O L G	0.5 X,O,I	F	0.004	O,I	X	0.0004 O,C	IM,I	ı	0.02 V O I G	O,IM,I	V O I	0.03	0.007	0.01
Methods	Г	X,O,I,G	A,O,I	<u>Г</u>	X,O,I,G	U,I	^	<u> </u>	I IIVI, I	ļ	X,O,I,G	U,IIVI,I	X,O,I	X,O,I,G	X,O,I,G	X,O,I,G
	Υ	Zn	Zr	1				1	T			1	T	1		
1 2	0.01	<0.001 <0.0010	0.000093 0.00091													
3		\U.UU IU	0.00091													
4			0.001													
5			0.005													
<sup>δ</sup>			<0.0001 <0.001													
8			10.001													
9																
10																
12																
13																
14 15																
Mean			0.002													
STDV.			0.002													
Certified	(<0.01)	(<0.001)	(0.002)													
95% C.I. Methods	Х	I	X,O,I													
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Legend: W = Classical, C = Combustion, F = Fusion, A = AA or GFAA, I = ICP or DCP, IM=ICP-MS, D = DC Arc, O = AES, X = XRF, G = GDAES or GDMS, H = Hollow Cathode AES



# **Participating Laboratories**

Anderson Laboratories, Inc.
Huntington Alloys Corporation
LECO Corporation
Oxford Instruments Analytical GmbH
Connecticut Metallurgical Inc.

Greendale, WI Huntington, WV St. Joseph, MI Uedem, Germany East Hartford, CT EAG Laboratories Laboratory Testing, Inc. Massachusetts Materials Research Liverpool, NY Hatfield, PA West Boylston, MA Manchester, NH

### **Traceability**

VHG Labs

Members of the "Inter-Laboratory Analysis Program" (ILAP) validate test methods and instrument performance utilizing SRMs, CRMs, and RMs produced by recognized Certifying Bodies. The specific SRMs, CRMs, and RMs applicable to the material covered by this certificate are:

ALPHA AR1648	ALPHA AR891	BS 625D	HT6308EV	IARM 241A	IARM 56D	LECO 501-502	LECO 502-870	NIST 1247
ALPHA AR1651	ALPHA AR946	BS 718A	IARM 202A	IARM 328A	IARM 57C	LECO 501-646	NIST 1208-1	NIST 864
ALPHA AR670	BCS 310/1	BS 718B	IARM 203A	IARM 52B	IARM 68C	LECO 502-016	NIST 1208-2	NIST 865
ALPHA AR872	BS 625A	HAS 945	IARM 207A	IARM 53A	JK37	LECO 502-411	NIST 1245	NIST 867
ALPHA AR882								

## **Homogeneity and Uncertainty**

"Uncertainty" values, as reported adjacent to certified concentration values, are based on a 95% Confidence Interval. These estimated uncertainties include the combined effects of method imprecision, material inhomogeneity, and any bias between methods. Homogeneity data from experimental XRF results are reflected in both the overall statistics and certified data. Homogeneity samples are selected by a systematic sampling procedure. The number of samples may be determined by equation 1, where N<sub>prod</sub> is the number of units produced and N<sub>min</sub> is the number of samples used for homogeneity testing. These samples are arranged in a simple randomized design such that each sample is analyzed multiple times by XRF. Homogeneity is also determined within sample using an applied version of ASTM E826. A single factor ANOVA is used to calculated uncertainty due to inhomogeneity (U<sub>hom</sub>). Uncertainty of the material is calculated by equation 2, where H=U<sub>hom</sub>, S= Standard deviation, t= t-value at 95% CI, and n= number of observations.

1. 
$$N_{min} = \max(10, \sqrt[3]{N_{prod}})$$
2.  $U_{CRM} = \frac{\sqrt{H^2 + S^2}}{\sqrt{n}} * t$ 

The International Standards Organization (ISO) definitions, expressed in ISO Guide 30–1992 list the following:

<u>Certifying Body:</u> Any technically competent body (organization or firm, public or private) that issues a reference material certificate with the information detailed in ISO Guide 31. The only generally accepted certifying body in the United States for primary standards or Standard Reference Materials (SRM) is the U. S. Department of Commerce, National Institute of Standards & Technology (NIST), Gaithersburg, MD. All other certifying bodies in the United States produce Reference Materials (RM) or Certified Reference Materials (CRM).

Reference Material (RM): Material or substance, with one or more property values that are sufficiently homogeneous and well established, to be used for the calibration of an apparatus, the assessment of a measurement method, or for assigning values to materials.

<u>Certified Reference Material (CRM):</u> Reference material, accompanied by a certificate, with one or more property values certified by a procedure, which establishes its traceability to an accurate realization of the unit in which the property values are expressed, and for which each certified value is accompanied by an uncertainty at a stated level of confidence.

<u>Inter-Laboratory Analysis Program (ILAP):</u> ASTM Standard E691-87 applies to inter-laboratory studies to "Determine the Precision of a Single Test Method", but also outlines a well thought out and logical plan for conducting an inter laboratory program involving multiple analytical techniques. Therefore, the guidelines established in ASTM E691-87 were applied to all aspects of this inter laboratory program, including the protocols for planning, handling, analysis and treatment of resulting data.

Methods of Analysis: The "Inter Laboratory Analysis Program" analyzes a wide variety of materials, and as a result, no single analytical method would provide optimum analytical results. Therefore, a combination of ASTM Standard Methods for classical wet chemistry, ICP, AA, Optical Emission, X-Ray spectrometric, and other accepted methods were used to produce analytical data. Carbon, Sulfur, Nitrogen, and Oxygen results were supplied from combustion and OE instrument procedures.

**Expiration of Certification:** The certification of this IARM is valid indefinitely, within the uncertainty specified, provided the IARM is handled and stored in accordance with the instructions stated on this certificate. The certification is nullified if the IARM is damaged, contaminated, otherwise modified, or used in a manner for which it was not intended.

Instructions for Use: The test surface is on the side opposite to the labeled surface, which includes the IARM number. The entire thickness of the unit is certified. However, the user is cautioned not to measure disks less than 2 mm thick when using X-ray fluorescence spectrometry. Each packaged disk has been prepared by finishing the test surface using a lathe. The user must determine the correct surface preparation procedure for each analytical technique. The user is cautioned to use care when either resurfacing the disk or performing additional polishing, as these processes may contaminate the surface. The minimum sample size for chips should be individually evaluated based on the analytical technique used; this would typically be greater than 0.1 grams. The material should be stored in a cool, dry location when not in use. Chips are not to be used for Oxygen analysis.

<u>Selection of Materials:</u> A "batch" or "series" is defined as a continuous length of bar produced from a single heat. The majority of IARM materials are in wrought condition; other methods of manufacture are utilized if necessary. ILAP samples are removed from equal sections from the total length of the bar. A portion of each section is converted to chips and a thin (pin) disk for analysis by classical wet chemistry, ICP, AA, and combustion procedures, and the balance remains as a thick disk for OES and X-Ray analysis.

David Coler, General Manager

**Analytical Reference Materials International** 

